

Refine Search

Search Results -

Terms	Documents
L4 and (glass near5 transition)	22

Database: US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search: L5

Search History

DATE: Monday, September 19, 2005 [Printable Copy](#) [Create Case](#)

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result set

<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>		
<u>L5</u> L4 and (glass near5 transition)	22	<u>L5</u>
<u>L4</u> L3 and ((second or first) near5 (resist or photoresist))	196	<u>L4</u>
<u>L3</u> L2 and ((pattern\$ or develop) same (resist or photoresist))	339	<u>L3</u>
<u>L2</u> L1 and (anti reflect\$ or antireflect\$ or ARC)	921	<u>L2</u>
<u>L1</u> ((resist or photoresist) near3 flow\$) or RFP	11387	<u>L1</u>

END OF SEARCH HISTORY